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	Application No.	Applicant(s)	
Notice of Allowability	10/008,796	HAUSSMANN ET AL.	
	Examiner	Art Unit	
	John S. Chu	1752	
The MAILING DATE of this communication ap All claims being allowable, PROSECUTION ON THE MERITS herewith (or previously mailed), a Notice of Allowance (PTOL- NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT of the Office or upon petition by the applicant. See 37 CFR 1.3	IS (OR REMAINS) CLOSED in 85) or other appropriate communic RIGHTS. This application is s	n this application. If not included unication will be mailed in due course. THIS	
1. This communication is responsive to <u>12/03/03</u> .			
2. The allowed claim(s) is/are <u>1-20</u> .			
3. The drawings filed on are accepted by the Exam	iner.		
 4. Acknowledgment is made of a claim for foreign priority a) All b) Some* c) None of the: 1. Certified copies of the priority documents h 2. Certified copies of the priority documents h 3. Copies of the certified copies of the priority International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DAT noted below. Failure to timely comply will result in ABANDO THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be su INFORMAL PATENT APPLICATION (PTO-152) which generated by the Notice of Draftsparation including changes required by the Notice of Draftsparation including changes required by the attached Examina Paper No./Mail Date [b) hereto or 2) to Paper No./Mail Date Identifying indicia such as the application number (see 37 CF each sheet. Replacement sheet(s) should be labeled as such 7. DEPOSIT OF and/or INFORMATION about the deattached Examiner's comment regarding REQUIREMENT. 	ave been received. ave been received in Application documents have been received in Application documents have been received. E" of this communication to file NMENT of this application. bmitted. Note the attached EXAgives reason(s) why the oath or must be submitted. person's Patent Drawing Review	on No In this national stage application from the din this national stage application from the a reply complying with the requirements AMINER'S AMENDMENT or NOTICE OF declaration is deficient. In the Office action of the drawings in the front (not the back) of R 1.121(d). ERIAL must be submitted. Note the	
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-94) 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/S Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for Depos of Biological Material	8) 6. Interview Si Paper No./ B/08), 7. Examiner's	formal Patent Application (PTO-152) ummary (PTO-413), 'Mail Date Amendment/Comment Statement of Reasons for Allowance John S. Chu Primary Examiner Art Unit: 1752	

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REASONS FOR ALLOWANCE

1. The following is an examiner's statement of reasons for allowance: The claimed invention is drawn to the following:

Claim 1 (original). A polybenzoxazole precursor comprising a partial structure selected from the group consisting of

wherein each of A^1 to A^7 is a univalent substituent independently selected from the group consisting of H, F, CH_3 , CF_3 , OCH_3 and OCF_3 ;

T is a residue selected from the group consisting of

wherein each of A^8 to A^{21} is a univalent substituent independently selected from the group consisting of H, F, CH_3 , CF_3 , OCH_3 and OCF_3 ;

wherein X is selected from the group consisting of $-CH_2-$, $-CF_2-$, $-C(CH_3)_2-$, $-C(CF_3)_2-$, $-C(OCH_3)_2-$, $-C(OCF_3)_2-$, $-C(OCF_3)_3-$

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$$C(CH_3)(C_6H_5)=$$
, $-C(C_6H_5)_2=$, $-O=$, $-(NH)=$, $-(N-CH_3)=$ and $-(N-C_6H_5)=$;

wherein M is selected from the group consisting of residues represented by formulas 10-14

in which Q is selected from the group consisting of C-H, C-F, C-CH₃, C-CF₃, C-OCH₃, C-OCF₃ and N,

and residues represented by formulas 15-34 shown below:

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wherein Q is defined as above, provided that at least one Q signifies N and a maximum of two N atoms are present per ring.

The claims are further drawn to a photoresist solution comprising said polybenzoxazole precursor of claim 1, a diazoketone and an organic solvent.

Claim 10 is drawn to the polybenzoxazole polymer made from the precursor.

Claim 20 is further drawn to a process for preparing a polybenzoxazole precursor.

The closest prior art references to the claimed invention are to EP-905,169 A2 and Ep 905,170 A2. These two references disclose diamine compounds very similar to the claimed diamines used to make the polybenzoxazole precursors, however the "Z" groups in '169 fail to

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teach the claimed "T" groups in the current application. Formulae 8 and 9 defined for the "T" group in claim 1 are not anticipated or rendered obvious by the "Z" groups of '163. The prior art lacks the particular bridging "M" group recited in the application (formula 10-14 of claim 1).

Likewise EP 905,170 A2 teaches a similar polybenzoxazole precursor, however the "Z" groups in '170 are the same as in '163, thus failing to anticipate or render obvious the claimed invention.

Because none of the prior art references of record disclose the claimed invention, claims 1-20 are seen as allowable and passed to issue.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

- 2. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. TERAMOTO et al, MERA et al and ROGERS et al are cited of interest to disclose heat-resistant polyamides.
- 3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Chu whose telephone number is (571) 272-1329. The examiner can normally be reached on Monday Friday from 9:30 am to 6:00 pm.

The fax phone number for the USPTO is (703) 872-9306.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (571) 272-1700.

John S. Chu

Primary Examiner, Group 1700

J.Chu May 17, 2004